Brian Beatty

Curriculum Vitæ

19 Twin Circle Drive Westport, CT 06880, USA Mobile: +34 677 684 381 ⊠ Brian.R.Beatty@Drexel.edu

Education

2011-Present M.S. Studies in Materials Science (Dual Degree), Politecnico di Milano, Milan, Italy.

Selected as one of Drexel University's first participants in the newly formed EAGLES International Exchange Program sponsered by the EU Commision and the US Department of Education and Cultural Affairs

2007-Present B.S./M.S. Studies in Materials Science (Major), Drexel University, Philadelphia, PA.

Cualified to Graduate with Honors

Cumulative GPA: 3.56 Junior/Senior GPA: 3.92

Selected as one of 15 STAR (Students Tackling Advanced Research) Scholars

Awarded A.J. Drexel Dean's Scholarship and William F. Mitchell SuperNOVA Scholarship

Master's thesis

Title Atomic Layer Deposition of Perovskite Oxide Thin Films

Supervisors Dr. Jonathan E. Spanier — Drexel University, Philadelphia, PA, USA

Dr. Carlo S. Casari — Politecnico di Milano, Milano, Italia

Description Atomic Layer Deposition (ALD) has been shown to be capable of depositing ultra-thin films (<100 nm) of perovskite oxides. These are technologically valuable due to their wide range of properties, ranging from ferroelectricity and ferromagnetism to superconductivity. With the use of ALD, it becomes possible to deposit thin and conformal coatings of these materials to three-dimensional surfaces with the ability to carefully control thickness with sub-nanometer resolution. Research work focuses on the lead titanate (PbTiO $_3$) end group of the lead zirconate titanate (PbTi $_x$ Zr $_{1-x}$ O $_3$) system.

Experience

Summer 2012 Thesis Research, Universidad Politécnica de Madrid, Madrid, Spain.

Completed remaining experiments and data analysis for M.S. thesis. Authored final M.S. thesis document.

Defended the project in collaboration with research groups from Spain, Italy, and the USA.

2009–2011 Research Experience, MesoMaterials Laboratory (MML), Drexel University.

Focused research on application of Atomic Layer Deposition to ferroelectric oxide thin films.

- o Co-Op Experiences were 6 month periods (Spring/Summer) of full time employment at MML.
- o Student Research was performed during periods when simultaneously attending courses.
 - 2011
 - Collaborated in development of ellipsometry analysis procedure for thin films
 - Designed new sub-system for ALD reactor, improving capabilities and minimizing precursor consumption
 - Lead international group in ALD oxide deposition, focused on both PbTiO₃ and BiFeO₃ systems
 - - Applied statistics-based design of experiments to solve a problem with interfering variables
 - Model- and simulation-driven process optimization to select precursors for improving yields
 - Determination of alternative reaction materials
 - 2009
 - Assumed leadership of PbTiO₃ project
 - Assigned to management and upkeep of ALD reactor

Fall, 2011 Abstract Accepted to MRS Fall Session.

On results of oriented lead titanate thin film deposition via ALD onto single crystalline surfaces.

Summer 2008 STAR: Summer Research Experience, MesoMaterials Laboratory, Drexel University.

Conceptualized and organized a personal reserah project that developed into a long term research and M.S. Thesis funded by the ARO.

- Data analysis (using Matlab and Igor software packages)
- o Training and over 150 hours of experience on various characterization tools

2007–2008 Training in Atomic Layer Deposition, MesoMaterials Laboratory, Drexel University.

Worked under graduate mentor Rahul Joseph researching application of advanced thin film deposition methods. Trained on operation and maintenance of ALD reactor,

Publications

April, 2012 **Shape-Controlled Vapor-Transport Growth of Tellurium Nanowires**, Christopher J. Hawley, Brian R. Beatty, Guannan Chen, and Jonathan E. Spanier, Crystal Growth & Design **2012** *12* (6), 2789–2793.

March, 2012 **The Ferroelectric Field Effect within an Integrated Core/Shell Nanowire**, Stephen S. Nonnenmann, Mohammad A. Islam, Brian R. Beatty, Eric M. Gallo, Terrence McGuckin, and Jonathan E. Spanier, Adv. Funct. Mater. **2012**.

Equipment Experience

Thin Film Atomic Layer Deposition (ALD), Chemical Vapor Deposition (CVD), Pulsed Laser Deposition (PLD), Molecular Beam **Deposition** Epitaxy (MBE), Sol-Gel Deposition, Thermal Evaporation, E-Beam Evaporation, R.F. Sputtering.

Film Analysis X-Ray Diffractometry (XRD), X-Ray Reflectivity (XRR), Scanning Electron Microscopy (SEM), Energy-Dispersive X-Ray Methods Spectroscopy (EDXS), X-Ray Fluorescence Spectroscopy (XRF), Ellipsometry, Rutherford Backscattering Spectroscopy, Photoluminescence.

Chemical Fourier-Transform Infrared Spectroscopy (FTIR), Differential Scanning Calorimetry (DSC), Thermo-gravimetric Analysis **Analysis** (TGA), Gas-Chromatography/Mass-Spectroscopy (GC-MS).

Electrical Hall Effect measurements, Cyclicvoltammetry (CV), Piezoelectric/Ferroelectric measurements, Piezoelectric force **Characteriza**- microscopy (PFM). **tion**

Computer skills

Languages MATLAB, Maple, LATEX, Igor

Tools Origin, Igor, LabView, FilmWizard,

Microsoft Office Suite, Adobe Suite

Platforms Mac OS, Windows

Spoken Languages

English Native Speaker

Spanish Speaking: Moderate

Reading: Moderate **Writing**: Moderate

Italian Speaking: Elementary

Reading: Elementary **Writing**: Elementary

Personal Interests

Electronics Design and synthesis of novel materials for IC applications, particularly those leveraging unique nanoscale properties

Energy Nanoscale structures for high-efficiency photovoltaic devices.

Culinary Arts Personal hobby.

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September 12, 2012

Human Resources Dept.

TriQuint Semiconductor, Inc. 2300 NE Brookwood Parkway Hillsboro, Oregon 97124

Dear Sir or Madam,

I am very interested in the position of Materials Engineer in your Research & Development department, particularly the position focusing on Thin Film depositions via MOCVD and ALD. Included with this letter is a copy of my Curriculum Vitæ, and I believe that you will find me to be a excellent candidate for this position.

I have significant experience with the techniques and project management relevant to this position, especially in the development and application of Atomic Layer Deposition (ALD) processes.

Your primary requirements for the applicant mentioned on the posting included the following:

Position Requirements:

- Experience with ALD for various types of thin films
- Knowledge of epitaxial deposition methods for semiconductors.
- Training and experience in materials characterization techniques

With a look at my CV you can see that I have matched or exceeded these qualifications.

Personal Qualifications:

- Over four years of personal and self-driven experience on developing novel ALD deposition methods; culminating in my M.S. Thesis
- Close collaboration and partnership with colleagues working in CVD of advanced materials (semiconductors, nanowires, etc.)
- Extensive and varied training in an array of advanced characterization methods

Through the process of obtaining my degree I have also worked in close collaboration with groups of varied backgrounds, was an integral part of numerous international partnerships, and have assisted on various projects with industry partners.

In short, I feel that I am a prime candidate for this position, and appreciate you taking the time to review my credentials and experience. Thank you very much in advance for your consideration of my application.

As an aside, I am out of the country until September 20th (9/20/2012). Until this date, I request that email be used for communication as my mobile phone number may change during this transition. I apologize for any inconvenience this may cause.

Sincerely,

Brian Beatty

Enclosure: Curriculum Vitæ